



Docket No.: 2336-256

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Inventor(s): Ju Hyun KIM et al.

U.S. Patent Application No. 10/810,634

Filed: March 29, 2004

For: METHOD FOR SEPARATING SAPPHIRE WAFER INTO CHIPS USING DRY-ETCHING

:  
:  
: Confirmation No. 9586  
:  
: Group Art Unit: 2812  
:  
: Examiner:

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

**LOWE HAUPTMAN & BERNER, LLP**

Benjamin J. Hauptman  
Registration No. 29,310

1700 Diagonal Road, Suite 310  
Alexandria, Virginia 22314  
(703) 684-1111 BJH/jk  
Facsimile: (703) 518-5499  
Date: August 29, 2005

INFORMATION DISCLOSURE CITATION IN ANOTHER APPLICATION (PTO-1449)		ATTY. DOCKET NO. 2336-256		U.S. PATENT APPLICATION NO. 10/810,634			
		APPLICANT <b>Ju Hyun KIM et al.</b>					
		FILING DATE March 29, 2004		GROUP 2812			
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
	6,583,032	6/2003	Ishikawa et al				
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	2001-81952A (US 6,583,032)	8/2001	Korea			X	
	2002-33592A	5/2002	Korea			X	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.